

L Number	Hits	Search Text	DB	Time stamp
1	17443	electrolyte and (titanium adj sulfate or titanium adj bromide or titanium adj trichloride or titanium adj idoide or titanium adj fluoride or copper sulfate) and anode	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/12 10:51
2	2490	semiconductor and (electrolyte and (titanium adj sulfate or titanium adj bromide or titanium adj trichloride or titanium adj idoide or titanium adj fluoride or copper sulfate) and anode)	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/12 10:51
3	409	seed adj layer and (semiconductor and (electrolyte and (titanium adj sulfate or titanium adj bromide or titanium adj trichloride or titanium adj idoide or titanium adj fluoride or copper sulfate) and anode))	USPÄT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/12 10:51
4	266	barrier adj layer and (seed adj layer and (semiconductor and (electrolyte and (titanium adj sulfate or titanium adj bromide or titanium adj trichloride or titanium adj idoide or titanium adj fluoride or copper sulfate) and anode)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/12 10:52
5	195	((cvd or chemical adj vapor adj deposition) or (pecvd or plasma adj enhanced adj chemical adj vapor adj deposition)) and (dielectric or oxide) and (barrier adj layer and (seed adj layer and (semiconductor and (electrolyte and (titanium adj sulfate or titanium adj bromide or titanium adj trichloride or titanium adj idoide or titanium adj fluoride or copper sulfate) and anode))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/12 10:54